	Тур е	Hit s	Search Text	DBs	Time Stamp	Comments	Error Definiti on	Errors
1	BRS	7		US-PGPUB; EPO; JPO; DERWENT;	2003/02/ 11 15:14			0
2	BRS	55	plasma with volt\$3 and implant\$5 with volt\$3 and potential and ion and chamber and cathode and anode		2003/02/ 06 10:39			0
3	BRS	1	increas\$3 with decreas\$3 with plasma with volt\$3 and increas\$3 with decreas\$3 with implant\$5 with volt\$3 and potential and ion and chamber and cathode and anode	1	2003/01/ 02 17:27			0
4	BRS	110	\$2generat\$3 and volt\$3 and	EPO; JPO; DERWENT; IBM_TDB	2003/02/ 05 15:37			O

	Тур е	Hit s	Search Text	DBs	Time Stamp	Comments	Error Definiti on	Errors
5	BRS	22	puls\$3 with plasma with volt\$3 and puls\$3 with implant\$5 with volt\$3 and potential and ion and chamber and cathode and anode	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 05 15:36			0
6	BRS	139	increas\$3 and decreas\$3 and plasma and implant\$5 and \$2generat\$3 and volt\$3 and potential and ion and chamber and cathode and anode and transistor and gate	EPO; JPO; DERWENT;	2003/02/ 05 18:09			0
7	BRS	101		US-PGPUB; EPO; JPO; DERWENT;	2003/02/ 05 18:40			0
8	BRS	1	puls\$3 with plasma with volt\$3 and puls\$3 with implant\$5 with volt\$3 and potential and ion and chamber and cathode and anode and transistor and gate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 05 21:45			0

	Тур	Hit s	Search Text	DBs	Time Stamp	COEEOCLS	Error Definiti on	Errors
9	BRS	6	plasma with volt\$3 and implant\$5 with volt\$3 and potential and ion and chamber and cathode and anode and transistor and gate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 05 21:50			0
10	BRS	49	increas\$3 and decreas\$3 and plasma and implant\$5 with gate and \$2generat\$3 and volt\$3 and potential and ion and chamber and cathode and anode and transistor	DERWENT; IBM_TDB	2003/02/ 05 22:45			0
11	BRS	180	\$2generat\$3 and volt\$3 and potential and ion and chamber and cathode and anode and transistor	EPO; JPO; DERWENT; IBM TDB	2003/02/ 05 15:38			0
12	BRS	0	•	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 06 10:41		·	0

	Typ e	Hit s	Search Text	DBs	Time Stamp	Comments	Error Definiti on	Errors
13	BRS	0	plasma with volt\$3 and implant\$5 with volt\$3 and potential and chamber and cathode and anode and nitrogen near gate near oxide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 06 10:42			0
14	BRS	0	chamber and	US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	! ? ^ ^ ? . ^ ? .			0
15	BRS	7	implant\$5 same volt\$3 and chamber and	EPO; JPO; DERWENT; IBM_TDB	2003/02/ 06 10:51		·	0
16	BRS	0	plasma same volt\$3 and implant\$5 same volt\$3 and chamber and nitrogen near gate near dielectric	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 06 10:50			0
17	BRS	10	plasma same volt\$3 and implant\$5 same volt\$3 and chamber and nitrogen near3 gate near3 oxide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 06 11:00			0

	тур	Hit s	Search Text	DBs	Time Stamp	C o m m e n t s	Error Definiti on	Errors
18	BRS	12	implant\$5 same	EPO; JPO;	2003/02/ 06 11:01			0
19	BRS	9	potential and	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB				О
20	BRS	4		US-PGPUB;				0
21	BRS	5	plasma with generat\$3 with volt\$3 and ion with implant\$3 with volt\$3 and nitrogen and transistor and gate	IBM_TDB	2003/02/ 11 16:17			0
22	BRS	76	plasma same ion same nitrogen and implant\$3 and volt\$3 and transistor and gate and puls\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/ 11 16:50			Ο